

WEST

Freeform Search

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ALL	"He" same plasma same etch\$ rate	137	L29
ALL	etch\$ rate same helium volume	1	L28
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ALL	5645947[uref]	0	L9
ALL	l7 and l2	172	L8
ALL	"Ar" same "He" same "H.sub.2"	1190	L7
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ALL	l4 and (chamber)	210	L5
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